

~~SECRET~~November 24th, 1959COCOM Document No. 3713.60/1COORDINATING COMMITTEERECORD OF DISCUSSIONONITEM 1360 - EQUIPMENT SPECIALLY DESIGNED FOR PURIFYING
AND PROCESSING SILICON AND GERMANIUM13th and 17th NOVEMBER, 1959

Present: Belgium (Luxembourg), Canada, France, Germany, Italy, Japan, Netherlands, United Kingdom, United States.

References: COCOM Documents 3715.00/1, 1959 Review W.P.4 and W.P.4/1360.

1. The UNITED STATES Delegation proposed that this item be redefined so as to read:

"Equipment for the manufacture of semi-conductor materials as follows;

- (a) Equipment specially designed for the production or processing of dendritic forms of any semi-conductor material, or combination thereof, suitable for use in diodes or transistors;
- (b) Equipment n.e.s., specially designed for purifying and processing silicon and germanium except equipment designed for the zone purification of germanium.

NOTE: The term "dendritic" signifies a ribbon-like product of semi-conductor material which may be drawn in various widths, thicknesses and lengths and which may represent processing stages from a relatively pure form of the material through advanced stages of treatment."

2. This proposal was accepted by the GERMAN, NETHERLANDS and UNITED KINGDOM Delegations. The FRENCH, ITALIAN and JAPANESE Delegations accepted ad referendum.

3. CONCLUSION. The Committee agreed that the study of this item would only be resumed in the course of the second round of the review in the event of non-confirmation of the ad referendum agreement.

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